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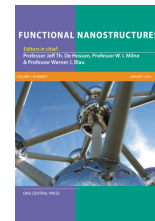


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Study of seahorse-like Fe-TiO₂ core-shell nanorods obtained in an induction heated MOCVD reactor

Andrea CRISBASAN^{1,a*}, Denis CHAUMONT^{1,b}, Marco SACIOTTI², Yvon LACROUTE¹, Remi CHASSAGNON¹

¹ICB ; Université de Bourgogne Franche-Comté, BP 47 870, 21078 Dijon, France.

²Departamento de Física – Universidade Federal de Pernambuco Recife Brazil.

^{*}Corresponding author

ABSTRACT

This paper presents the growth of Fe-TiO₂ COaxial Heterostructure Nanorods (COHN) by Metal-Organic Chemical Vapour Deposition (MOCVD). The Fe-TiO₂ COHN were grown in one step on silicon based substrates, using titanium isopropoxide as precursor and ferrocene as catalyst. Various growth parameters (deposition time, temperature and substrates) were modified to define a growth model. Samples' morphology and structure were characterized by SEM and Fe-TiO₂ COHN were extensively analyzed by TEM, EDS, SAED and EELS. These techniques show the coaxial structure of Fe-TiO₂ COHN and confirm that the core is pure iron, while the shell is titanium dioxide.

I. INTRODUCTION

Metal oxides are interesting materials with many properties. A lot of these properties are depending on the metal oxides' surfaces or the interfaces between them and other materials [1][2]. TiO₂ is extensively studied because of its interesting chemical, electrical and optical properties. Its applications vary with its form (bulk or nano). TiO₂ layers are used in dye-sensitized photovoltaic cells. Other applications would be protective layers for large scale integrated circuits and optical elements, gas sensors or antireflective coatings [3][4].

There are many ways to prepare TiO₂ layers. Among these preparation methods, the Chemical Vapour Deposition method with organometallic precursors (MOCVD method), is a promising one to obtain nanostructured surfaces. From the variety of TiO₂ nanostructures deposited by MOCVD, original and reproducible 2D (wires) and 3D (membranes, crucibles, trees...) nanostructures can be obtained [5] by varying growth parameters and catalysts.

Fe-TiO₂ COaxial Heterostructure Nanorods were also obtained. This subject will be detailed in this

paper. Growth parameters have been varied and their effects on these structures have been studied (deposition time, temperature, SiO₂ layer...) [6]. Also the Fe-TiO₂ COHN were characterized by SEM and TEM techniques.

Some coaxial heterostructure nanowires are presented in literature. However, they are deposited in multiple steps using other technical parameters and materials [7][8]. Other similar coaxial structures would be the filled carbon nanotubes realised in one step. They have a core made out of iron, nickel or cobalt, depending on the used catalyst, but they do not contain any TiO₂ and they are not obtained using induction heating [9][10][11].

Therefore, the growth process of Fe-TiO₂ coaxial heterostructures nanorods in presence of a magnetic catalyst in a magnetic field by MOCVD is part of a new domain that we are going to deepen.

II. MATERIALS AND METALS

Reagents

The precursor, titanium (IV) isopropoxide

($\text{Ti}(\text{OC}_3\text{H}_7)_4$) (99.999% metals basis) and ferrocene ($\text{Fe}(\text{C}_5\text{H}_5)_2$) (98%), were purchased from Sigma Aldrich.

Synthesis of Fe-TiO₂ COHN

Fe-TiO₂ COHN were grown in a home-made MOCVD system. The silicon based substrates were placed on a graphite susceptor inside a silica glass tube, surrounded by an induction heating coil. The induction system, provided by FIVES CELES, is an aperiodic generator HF 6kW working at 400 kHz. In the silica glass reactor, a dynamic vacuum was maintained at 76 torr under N₂ constant flow (1.2 L/min). The titanium isopropoxide source was maintained at 40°C and the ferrocene source at 50°C. These precursors were introduced into the reactor by the carrier gas (N₂) flowing through their containers at a rate of 0.6 L/min each.

When the precursor molecules were in contact with the 550°C heated substrate, they were decomposed by pyrolysis and TiO₂ grew. Without catalysts, TiO₂ columns are usually obtained. In the presence of catalysts, such as ferrocene, original 2D-3D nanostructures were obtained, like the Fe-TiO₂ COHN.

Fabrication method of substrates

In order to have silicon without SiO₂, the substrates were cleaned by sputtering under an argon flow.

A silica glass substrate was used for the pure amorphous SiO₂ substrate. To obtain silicon with amorphous SiO₂ layer, a PVD method at ambient temperature was used. To ensure silicon with crystalline SiO₂, a SiO₂ layer was grown applying a heat treatment to the substrate in an oxide atmosphere at 950°C for 60 min. Another substrate was used without cleaning, leaving the native SiO₂ islands untouched.

Studied parameters

To understand the growth process and eventually build a growth model, the influence of three growth parameters was studied: deposition time, deposition temperature and the substrate type. The deposition time ranged from 5 to 100 minutes

to see the first instants of the growth as well as the morphology of the TiO₂ nanorods at long deposition times.

The deposition temperature varied between 400°C and 750°C, in order to be in the decomposition temperature range of the ferrocene.

Various silicon based substrates were used: silicon without SiO₂, amorphous SiO₂, silicon with amorphous SiO₂ layer, silicon with crystalline SiO₂ layer, silicon with crystalline SiO₂ islands.

Characterisation

Scanning Electron Microscopy (SEM) images were obtained on a JEOL JSM 6400F SEM operating at 20 kV. Transmission Electron Microscopy (TEM) experiments were conducted on a JEOL JEM-2100F microscope operated at 200 kV and fitted with an ultrahigh resolution pole piece achieving a point to point resolution of 0.19 nm. A detailed analysis was carried out with the different features of the TEM: Scanning Transmission Electron Microscopy (STEM), Energy Dispersive Spectroscopy (EDS, Bruker XFlash Detector 5030 spectrometer), Selected Area Electron Diffraction (SAED) and Electron Energy Loss Spectroscopy (EELS, Gatan GIF Tridiem).

III. RESULTS AND DISCUSSION

The results are divided in two sections. The first presents the study growth parameters and their influence on the TiO₂ nanostructures. The second consists of the thorough characterization of Fe-TiO₂ COHN.

Growth parameters

Deposition time

The other growth parameters remain constant: T = 550°C; silicon with crystalline SiO₂ islands substrate. The SEM images (figure 1) show the obtained TiO₂ layers when varying the deposition time. By depositing TiO₂ for a short time, 5 - 10 min, the first steps of the growth are visible. The longer deposition times should show how the TiO₂ nanorods react to a longer exposure of precursor inflow and longer heating.

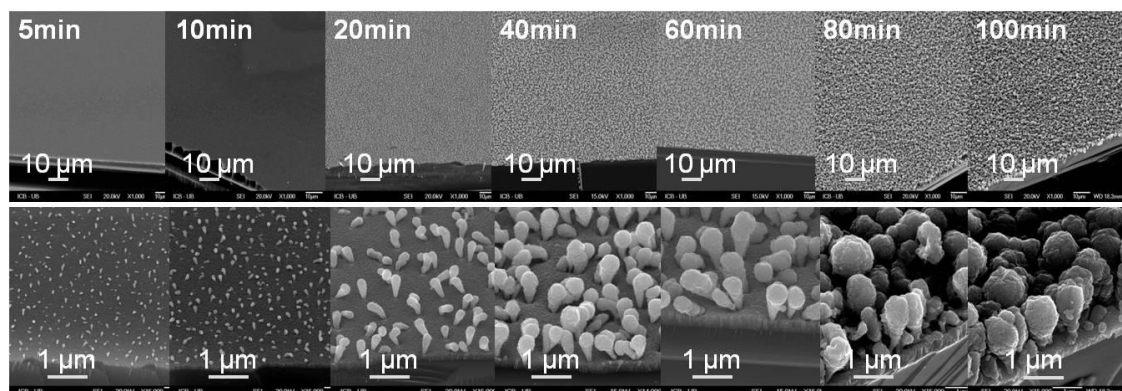


Figure 1 SEM images: Homogeneity of the TiO₂ layer and evolution of height and head diameter of TiO₂ nanorods with time (T = 550°C; silicon with crystalline SiO₂ islands substrate).

For each studied deposition time, a homogeneous distribution of TiO_2 nanorods can be observed on the substrate's surface. At higher magnifications, on the silicon with crystalline SiO_2 islands substrate a TiO_2 layer can be observed (figure 2), also seen in depositions without ferrocene, on which TiO_2 nanorods grow. The TiO_2 nanorods are composed of a stem ending in a spherical head.

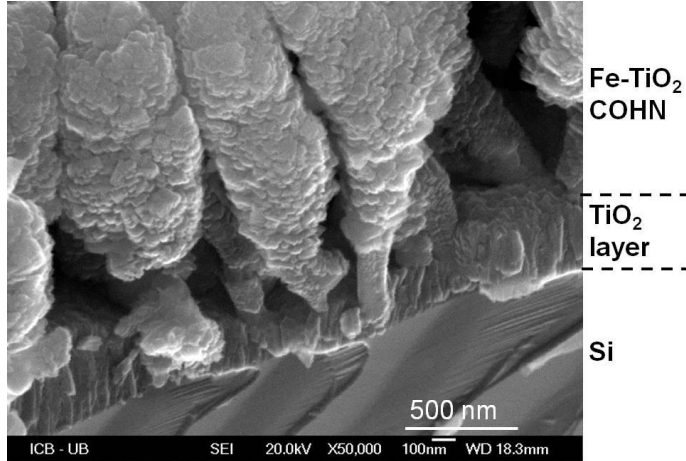


Figure 2 SEM image: TiO_2 layer and TiO_2 nanorods deposited on silicon with crystalline SiO_2 islands substrate, $T=550^\circ\text{C}$, $t=100$ min.

For a given deposition time the size distribution of the height and head nanorods is very narrow, thus a quantitative analysis of the nanorods' size with time could be done, as seen in figure 3.

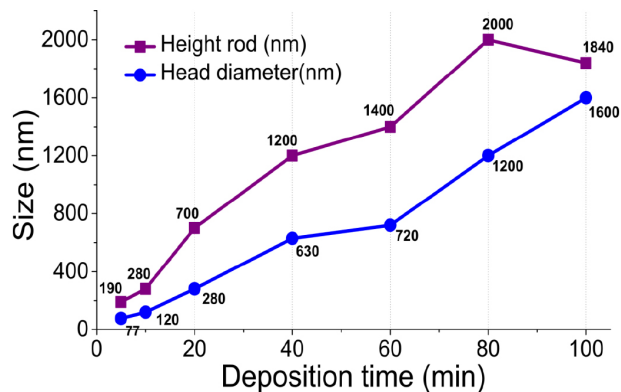


Figure 3 Evolution of height and head diameter of TiO_2 nanorods with deposition time.

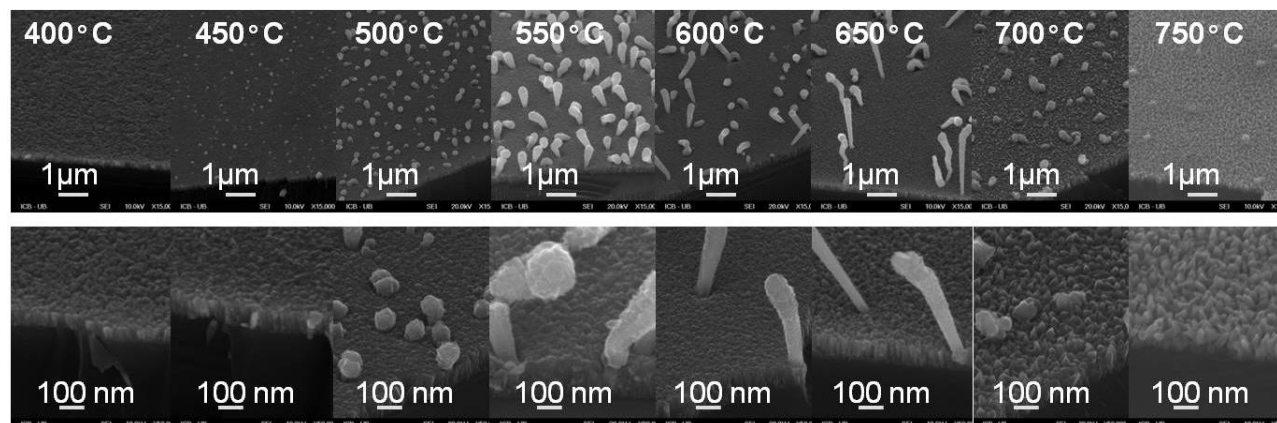


Figure 4 SEM images: Evolution of TiO_2 nanorods with temperature ($t=20$ min; silicon with crystalline SiO_2 islands substrate).

After 5 minutes of deposition, TiO_2 nanorods have already a height of 190 nm and a head diameter of 77 nm. With longer deposition times nanorods reach a height of 2 μm and a head diameter of 1.2 -1.6 μm . At 80 - 100 min of deposition time, the heads start to touch each other, resulting in a second TiO_2 layer. This layer presents a superhydrophobic character, where the water drop keeps its round form, but does not slide from the surface.

At the beginning of the deposition, TiO_2 nanorods start to grow in certain nucleation sites. With increasing time of deposition, a higher quantity of reagents will enter the reactor and reach the sample. This matter is deposited on the higher points of the TiO_2 layer, these being the already existing nanorods, especially the heads. The heads will grow until they eventually touch each other, building the second TiO_2 layer seen in figure 2.

Deposition temperature

The other growth parameters remain constant: $t=20$ min; silicon with crystalline SiO_2 islands substrate. Knowing that the TiO_2 nanorods start growing at over 550°C , the question was how a different temperature would influence these structures. A step of 50°C was decided starting from 400°C , ferrocene being stable until this temperature. The upper limit was set at 750°C .

Figure 4 shows that at 400°C and 450°C , a TiO_2 layer without any nanorods is created. At 500°C , head like structures begin to appear on a prior formed titanium layer. Above the usual temperature, at 600°C and 650°C , an increase in height is seen, but not in head diameter. Starting from 700°C , the TiO_2 layer structure and morphology changes altogether. It is built of massive TiO_2 crystals.

The quantitative evolution of both, height and head diameter, of TiO₂ nanorods between 500°C and 650°C is presented in figure 5.

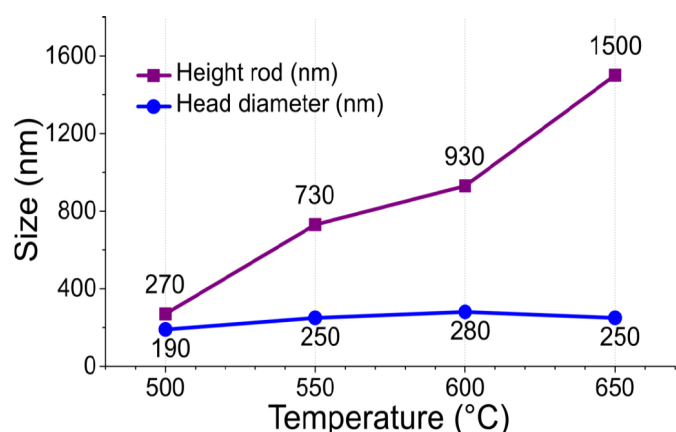


Figure 5 Evolution of height and head diameter of TiO₂ nanorods with temperature.

By varying the deposition temperature the head diameter does not change but the height of the TiO₂ nanorods is highly influenced. For a temperature difference of 150°C the height increases 5 times. It starts at 500°C with a height of 270 nm being almost buried in the TiO₂ initial layer, reaching a height of 1.5 μm at 650°C.

In order to obtain TiO₂ nanorods, a temperature between 500°C and 650°C is necessary. At lower temperatures the catalyst is not yet decomposed and at higher temperatures the structure of TiO₂ layer changes. Also, the increase of deposition temperature results in higher TiO₂ nanorods. This could be explained by the effect that temperature has on the reactions rate. The percentage of reactant molecules that have sufficient energy to react is higher at higher temperatures (the thermal energy being greater than the activation energy $E > E_a$).

Substrates

The other growth parameters remain constant: $t = 20$ min; $T = 550^\circ\text{C}$. While searching for parameters responsible for the growth of TiO₂ nanorods, the point of interest shifted towards the presence of SiO₂. TiO₂ depositions were realised on different types of SiO₂ layers, amorphous and crystalline as described before. Growth without SiO₂ (Substrate: Silicon without SiO₂) is presented in figure 6.

The TiO₂ layer, that usually appears, can be observed. On the surface there are some small structures, but no nanorods.

Growth on amorphous SiO₂ (Substrate: Silica glass, Silicon with amorphous SiO₂ layer) is presented in figure 7a and 7b.

Figure 7a shows the TiO₂ layer deposited on a silica glass. A structured TiO₂ layer is visible, but no nanorods are present. Figure 7b shows the TiO₂ deposited on silicon with an amorphous SiO₂ layer is presented. The initial TiO₂ layer is present and some isolated seahorse-like seeds show up.

Growth on crystalline SiO₂ (Substrate: Silicon with

crystalline SiO₂ islands, Silicon with crystalline SiO₂ layer) is presented in figure 7c and 7d. On both samples, a homogenous distribution of TiO₂ nanorods is clearly recognizable. On the silicon with crystalline SiO₂ islands the nanorods are higher and better developed than on the silicon with crystalline continuous SiO₂ layer.

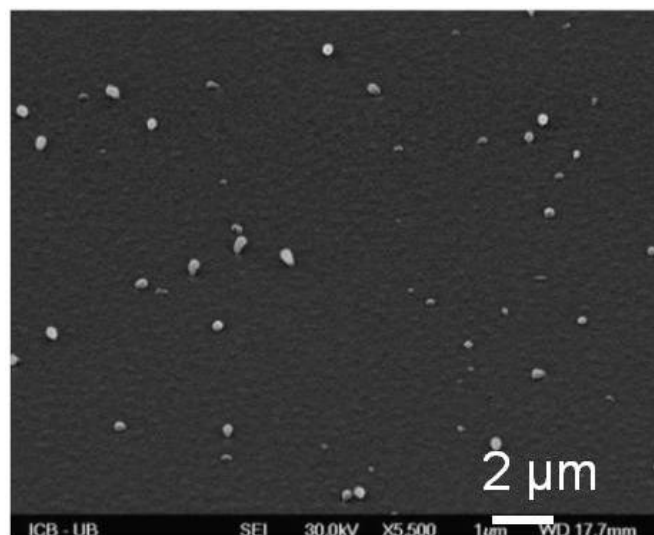


Figure 6 SEM image: TiO₂ layer on Silicon without SiO₂ ($t = 20$ min; $T = 550^\circ\text{C}$).

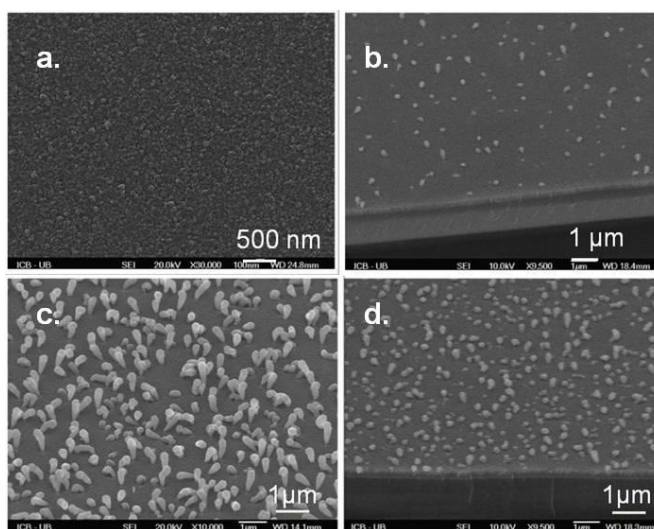


Figure 7 SEM images: TiO₂ layer on silica glass (a), on silicon with amorphous SiO₂ layer (b), on silicon with crystalline SiO₂ islands (c), on silicon with crystalline SiO₂ layer (d) ($t = 20$ min; $T = 550^\circ\text{C}$).

It is obvious that the presence of crystalline SiO₂ is a necessity for the growth of TiO₂ nanorods. The crystalline SiO₂ layer favors the appearance of Fe-TiO₂ COHN, but in order to have the desired shape of Fe-TiO₂ COHN, crystalline SiO₂ islands are necessary. In literature, a growth model explains the influence of the oxide on the growth: it is called the Oxide Assisted Growth model, where the growth is induced by the oxide and not metal catalysts [12][13]. But, mostly the oxide is present in powder form, not as a layer. Other articles show that a SiO₂ layer can be a guide for the growth direction of nanowires [14].

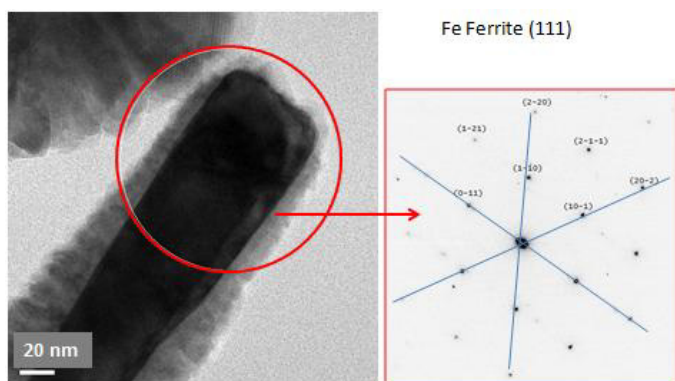


Figure 10 Crystallographic analysis: analyzed core area (left side) and experimental diffraction pattern of Ferrite (right side).

The crystallographic analysis points out that the core is a pure iron phase.

Electron energy loss spectroscopy

To confirm that the core is not an iron oxide, electron energy loss spectroscopy was utilized. This is an analytical technique that measures the change in kinetic energy of electrons after they have interacted with a specimen. When carried out in a TEM, EELS can give structural and chemical information about a solid [15]. Figure 11 shows the analyzed area and its respective EELS spectrum background extracted.

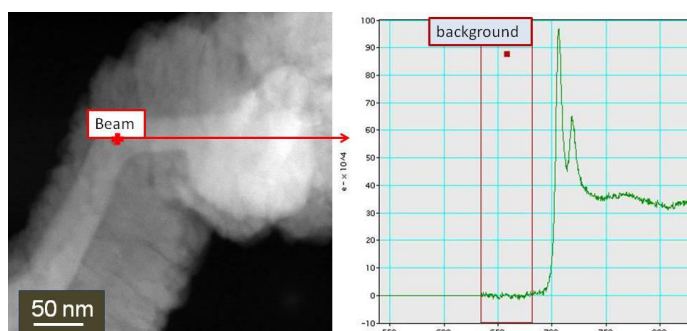


Figure 11 EELS analysis: left: analyzed zone; right: EELS spectrum of L_{23} Fe edge.

The experimental EELS spectrum of L_{23} Fe edge exhibits no pre-edge shoulder (feature commonly observed for iron oxides) as shown in figure 12. This confirms that the core is made of pure iron.

These original Fe- TiO_2 COHN structures are new to the literature. The only similar structures found would be the iron filled CNT. They have the same coaxial form: a shell and a core. The core is also made of iron, because ferrocene is used as a catalyst, but the shell is made of carbon, while in our case the shell is made of TiO_2 . The growth models described for the CNT with ferrocene catalyst are the base and tip growth mode. Base growth mode consists in a metal catalyst that remains on the substrate surface while the CNT grows beginning from it. The tip growth mode assumes that the metal catalyst detaches from the substrate and ends up at the tip of the CNT. For iron filled CNT however, the growth mode would be a combined mode: the iron enters through the open tip of the

carbon shell, then a larger catalyst particle attaches to the tip, increasing the speed of the growth. This change in pressure causes the large catalyst particle to fall into the CNT and filling it. [19]

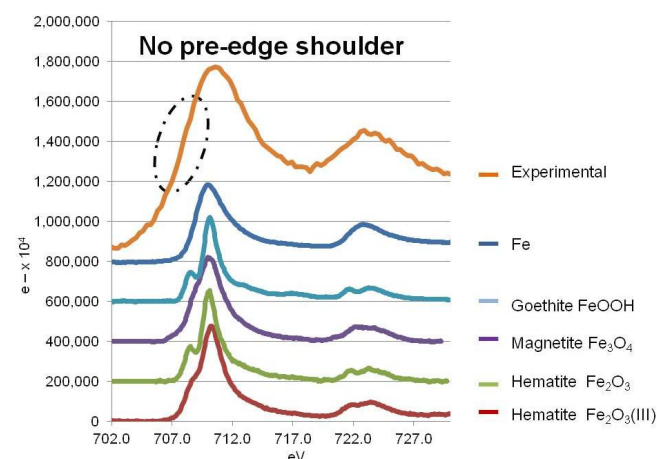


Figure 12 Comparison of the experimental EELS spectrum with the EELS spectra of iron (Fe) [16], Goethite ($FeOOH$) [17], Magnetite (Fe_3O_4) [17], Hematite (Fe_2O_3) [17], Hematite (Fe_2O_3) (III) [18] found in literature.

IV. CONCLUSIONS

In the present study reproducible Fe- TiO_2 core-shell nanorods were successfully grown on silicon wafers from titanium isopropoxide precursor, in the presence of ferrocene as a catalyst. Their nanosize and structure was confirmed by techniques as SEM, TEM, EDS, SAED and EELS.

In order to establish a growth model for Fe- TiO_2 COHN, it needs to be considered that the core iron comes from the ferrocene catalyst, which makes the presence of ferrocene a necessity. This limits the deposition temperature interval, because ferrocene needs to be decomposed, but not to totally disappear. Also, on the substrate crystalline SiO_2 islands are needed, and not as a continuous layer.

All Fe- TiO_2 COHN of one sample have the same size and they are built of a TiO_2 shell (anatase, rutile and brookite crystallites) and a pure iron core. Their size (height, head diameter) increases with time, building a second TiO_2 layer.

We propose that the Fe- TiO_2 COHN growth is related to the induction heating method (using a alternative magnetic field). This field would interact with the ferromagnetic catalyst creating "hot spots"- nucleation points. It would also orient the ferromagnetic particles of the catalyst creating the vertical iron cores. This line of thought is yet to be explored in order to define a more precise growth model.

V. REFERENCES

- [1] Marcos Fernández-García, José A. Rodríguez, Synthesis, properties, and applications of oxide nanomaterials, John Wiley & Sons, Inc, New Jersey, 2007

- [2] Victor E. Henrich, P. A. Cox, *The Surface Science of Metal Oxides*, Cambridge University Press, 1996
- [3] D. P. Macwan, Pragnesh N. Dave, A review on nano-TiO₂ sol-gel type syntheses and its applications, *J Mater Sci* 46, (2011) 3669–3686
- [4] Xiaobo Chen, Samuel S. Mao, *Titanium Dioxide Nanomaterials: Synthesis, Properties, Modifications, and Applications*, *Chem. Rev.* 107 (2007) 2891–2959
- [5] A. Crisbasan et al., Study of TiO₂ obtained by an induction heated MOCVD reactor, *Applied Surface Science* 358 (2015) 655–659
- [6] Mandel et al., Growth Mechanism of Self-Catalyzed Group III–V Nanowires, *Nano Lett* 10 (2010) 4443–4449
- [7] A. Majumdar et al., US Patent 6,882,051 13, (2005)
- [8] J. Johansson and K. A. Dick, Recent advances in semiconductor nanowire heterostructures, *CrystEngComm* 13 (2011) 7175–7184
- [9] J. Cheng, X.P. Zou, G. Zhua, M.F. Wang, Y. Sua, G.Q. Yang, X.M. Lü, Synthesis of iron-filled carbon nanotubes with a great excess of ferrocene and their magnetic properties, *Solid State Communications* 149 (2009) 1619–1622
- [10] A. Leonhardt, M. Ritschela, R. Kozhuharova, A. Graffa, T. Müller, R. Huhleb, I. Mönnch, D. Elefanta, C.M. Schneider, Synthesis and properties of filled carbon nanotubes, *Diamond and Related Materials* 12 (2003) 790–793
- [11] Uhlend Weissker, Silke Hampel, Albrecht Leonhardt and Bernd Buchner, Carbon Nanotubes Filled with Ferromagnetic Materials, *Materials* 3 (2010) 4387–4427;
- [12] Rui-Qin Zhang, Yeshayahu Lifshitz, Shuit-Tong Lee, Oxide-Assisted Growth of Semiconducting Nanowires, *Advanced Materials* 15 (2003) 635–640
- [13] Sivasankar, *Engineering Chemistry*, Tata McGraw-Hill Publishing Company Limited, New Delhi, 2008
- [14] Nathaniel J Quitariano, Wei Wu and Theodore I Kamins, Guiding vapor-liquid-solid nanowire growth using SiO₂, *Nanotechnology* 20 (2009) 145303
- [15] Information on <http://www.gatan.com/techniques/eels>
- [16] A. Feldhoff, J. Martynczuk, M. Arnold, M. Myndyk, I. Bergmann, V. Sepelak, W. Gruner, U. Vogt, A. Hähnel, J. Woltersdorf, *Journal of Solid State Chemistry* 182, 2961–2971 (2009)
- [17] A. Gloter, A. Chen from EELS database: <https://eelsdb.eu>
- [18] Y. Pan, A. Brown, R. Brydson, A. Warley, A. Li, J. Powell, Electron beam damage studies of synthetic 6-line ferrihydrite and ferritin molecule cores within a human liver biopsy, *Micron* 37 (2006) 403–411
- [19] Zhang, X.; Cao, A.; Wei, B.; Li, Y.; Wei, J.; Xu, C.; Wu, D. Rapid growth of well-aligned carbon nanotube arrays. *Chem. Phys. Lett.* 362 (2002) 285–290.